Docket No.	
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	the original, first and sole w) of the subject matter w	hich is claimed and	d for which a patent is sot	ight on the inver	ntion entitled	•	
Insert Title)	THERMOPLASTI	C RESIN C	OMPOSITION, M	ATERIAL	FOR SUBS	TRATE	AND
	FILM FOR SUB						
ne specificati	on of which is attached he	reto unless the foll	owing hox is checked:				
×23	filed on Decembe	dom December 14, 2004		As PCT International Application			
Nur	nber PCT/JP200	4/018623	and was amonded on	_			
	filed on			As U.S. Pater	nt Application		
Nur	nber		and was amended on				<u> </u>
hereby clair ertificate, or nd have also	the duty to disclose infor in forcign priority benefit §365(a) of any PCT Internifect identified below any force at of the application(s) for	s under 35 U.S.C actional application ion application for	i. §119(a)-(d) or §365(b) n which designated at lear r natent or inventor's cert	of any foreign tone country of	application(s) ther than the Un nternational App	oited States, plication ha	listed belo
	417175/2007	<b>-</b>	45/10/			ty Claimed	
(List pnor	417175/2003 (Number)	Japan	15/12/		\\ \times \\	es 🗌 No	
foreign	(/telliod/	Number) (Country) (Day/M		h/Year Filed) Yes No			
applications)	(Number)	(Country)	(Day/Mont	h/Year Filed)			
2bhiteattous)	(Number)	(Country)	(Day/Mont	th/Year Filed)	□ Y	cs 🔲 No	
·	(Number)	(Country)	<u> </u>	h/Year Filed)	DY	cs 🗌 No	
		(Country) C. §119(c) of any	(Day/Mon	h/Year Filed)		cs 🗌 No	
	(Number) the benefit under 35 U.S. (Application Nu	(Country) C. §119(c) of any mber)	(Day/Mont	h/Year Filed)		cs 🗌 No	
	(Number) the benefit under 35 U.S.  (Application Nu	(Country) C. §119(c) of any mber)	(Day/Mont United States provisional (Filing Date)	h/Year Filed) application(s) li	sted below.	cs 🗌 No	
	(Number) the benefit under 35 U.S.  (Application Nu	(Country) C. §119(c) of any mber)	(Day/Mont	h/Year Filed) application(s) li	sted below.	cs 🗌 No	
hereby claim hereby claim esignating th isclosed in the uty to disclose f the prior ap	(Number)  the benefit under 35 U.S.  (Application Number)  (Application Number)  Sec at the benefit under 35 U.S.  the United States of Americal prior application(s) (U.S.)  is information which is may plication and the national	(Country) C. §119(c) of any mber) tached list for addition S.C. §120 of any ca listed below and S. or PCT) in the startial to patentability or PCT Internation	(Day/Mont United States provisional  (Filing Date)  (Filing Date)  tional prior foreign or pro United States application and, insofar as the subject manner provided by the lity as defined in 37 C.F.F. and filing date of this appli	h/Year Filed) application(s) li visional applica (s) or §365(c) of matter of each first paragraph k. §1.56 which be cation.	tions.  of any PCT Into of the claims of 35, U.S.C. § secame available	emational a f this appli 112, I ackn between th	cation is n lowledge the filing da
hereby claim hereby claim lesignating th isclosed in the	(Number)  the benefit under 35 U.S.  (Application Number)  (Application Number)  See at the benefit under 35 U.S.  the United States of Americal prior application(s) (U.S.)  (Exprise information which is marginated and the national plication and the national (Application Series)	(Country) C. §119(c) of any mber) mber) tached list for addition S.C. §120 of any ca listed below ar S. or PCT) in the atterial to patentability or PCT Internation at No.)	(Day/Mont United States provisional (Filing Date) (Filing Date) tional prior foreign or pro United States applicational, insofar as the subject manner provided by the lity as defined in 37 C.F.F.	h/Year Filed) application(s) li visional applica (s) or §365(c) of matter of each first paragraph k. §1.56 which be cation.	tions.	emational a f this appli 112, I ackn between th	cation is n lowledge the filing da

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The undersigned hereby authorizes the U.S. attorneys named herein to accept and follow instructions from the undersigned's assignee, if any, and/or, if the undersigned is not a resident of the United States, the undersigned's domestic attorney, patent attorney or patent agent, as to any action to be take in the Pstent and Trademark Office regarding this application without direct communication between the U.S. attorneys and the undersigned. In the event of a change in the person(s) from whom instructions may be taken, the U.S. attorneys named herein will be so notified by the undersigned

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further, that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or amprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

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	Date						
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